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Amendments to the Abstract:

~~The present invention provides a display device which can reduce the~~ The
irregularities of characteristics of a pair of transistors, which are prepared by a
pseudo single crystallizing technique ~~and are used in a differential amplifying circuit~~
~~or the like, are reduced.~~ To achieve this, semiconductor
layers are formed on a substrate and ~~having~~ have pseudo single crystal regions
therein, and a plurality of thin film ~~transistor~~ transistors are arranged in the inside of
the pseudo single crystal regions. ~~Out of the plurality of thin film transistors, two~~ Two
or more of the plurality of thin film transistors, which are required to exhibit small
irregularities relative to each other as ~~the characteristics of the transistors thereof,~~
have the direction of a the length of the gates of the respective thin film transistors
arranged ~~with~~ at an inclination of within ± 20 degree with respect to the longitudinal
direction of the strip-like grown crystals, and they are arranged such that, when
channel regions of the respective thin film transistors are imaginarily extended in
parallel to the growth direction of the strip-like grown crystals, at least portions of the
channel regions are ~~superpose~~ superposed on each other.